

In the United States Patent and Trademark Office

Date:	HEREWITH		
In re	Ashima Chakravarti, et al.	Filed:	1/20/04
Application of:			
For:	Polycrystalline Silicon Layer With Nano-Grain Structure And Method of Manufacture		
Serial Number:	10/707,878	Confirmation No.	1877
Art Unit:	2891	Examiner:	SMITH, BRADLEY

AMENDMENT AFTER FINAL REJECTION

Hon. Commissioner of Patents and Trademarks
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed October 27, 2006, the present application is amended as follows: